

## Supporting Information

# Hierarchical MoS<sub>2</sub>-carbon porous nanorods towards atomic interfacial engineering for high-performance lithium storage

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## Author Contributions

The manuscript was written through contributions of all authors. All authors have given approval to the final version of the manuscript.

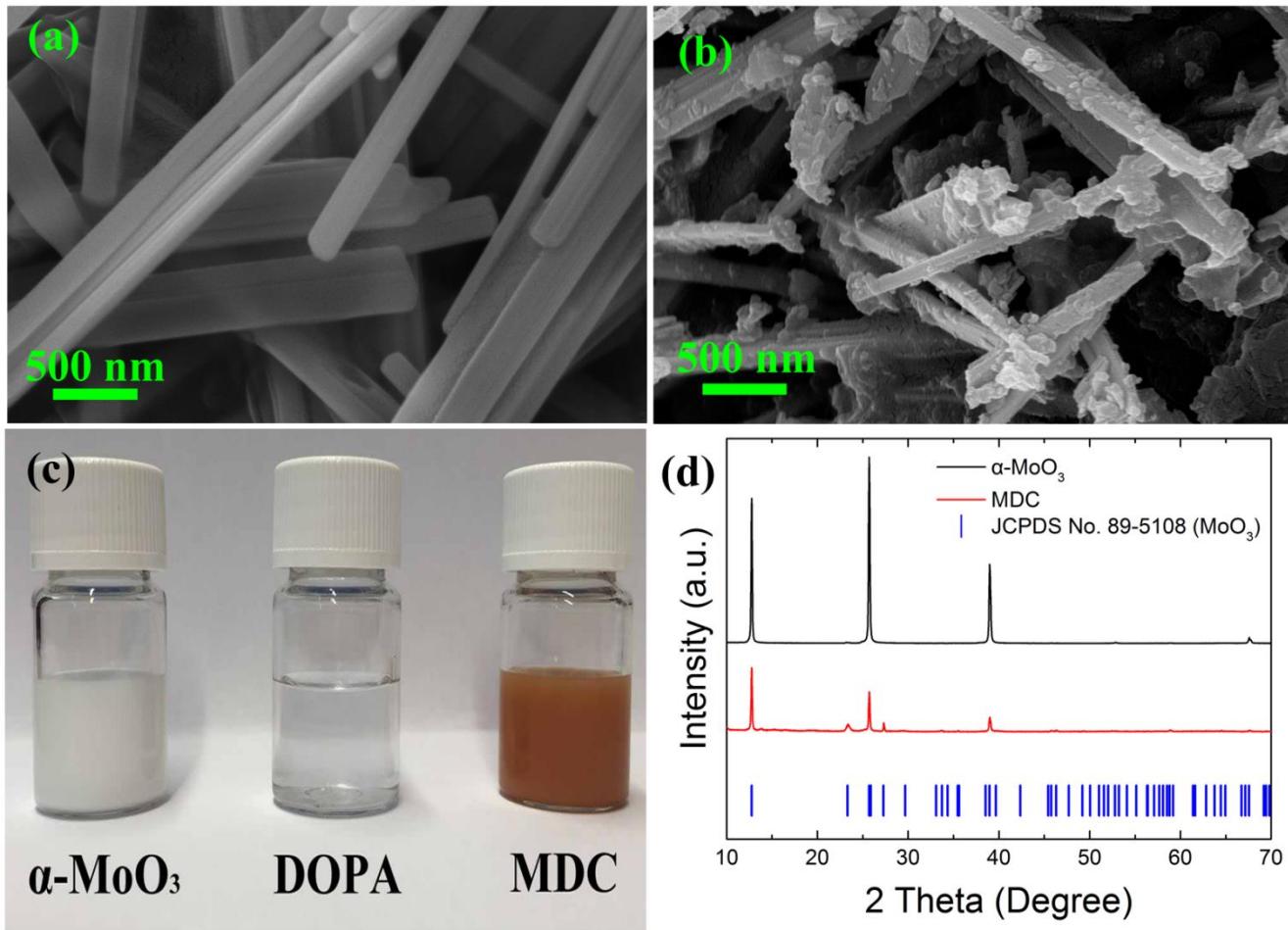
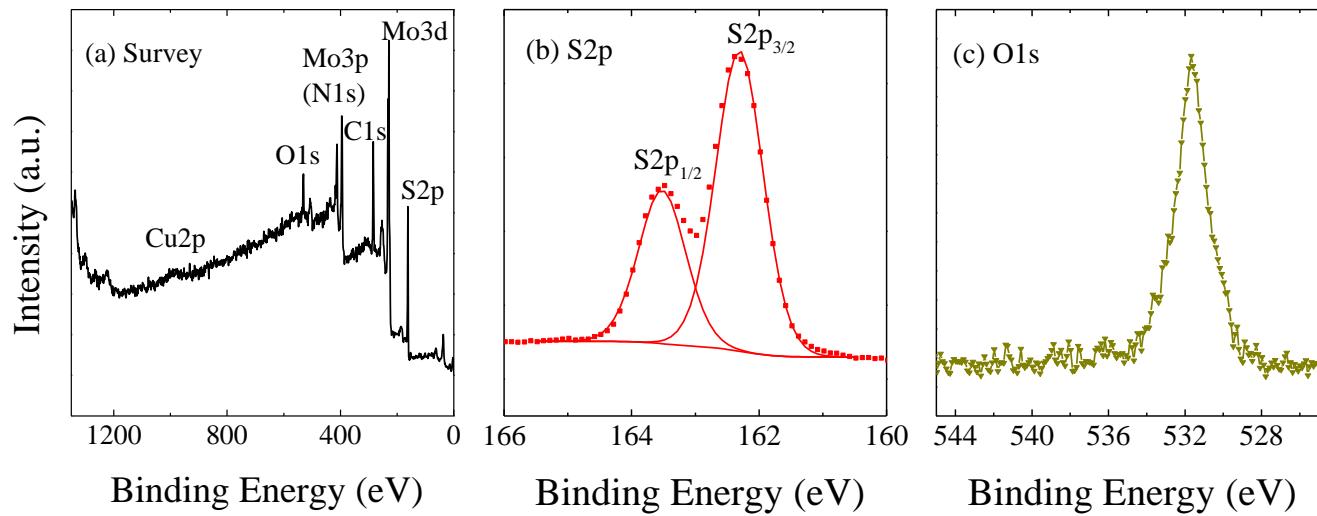


Fig. S1: SEM images of  $\alpha\text{-MoO}_3$  nanorods (a) and MDC (b); photo image of  $\alpha\text{-MoO}_3$  nanorods, DOPA and MDC water solution (c); and XRD pattern of synthesized  $\alpha\text{-MoO}_3$  nanorods, MDC, and standard pattern of  $\alpha\text{-MoO}_3$  according to JCPDS No. 89-5108 (d).



*Fig. S2: XPS measurements of the MoS<sub>2</sub>/NC-PNR superstructure: (a) survey scan, (b)~(c) high resolution scans of S2p and O1s.*

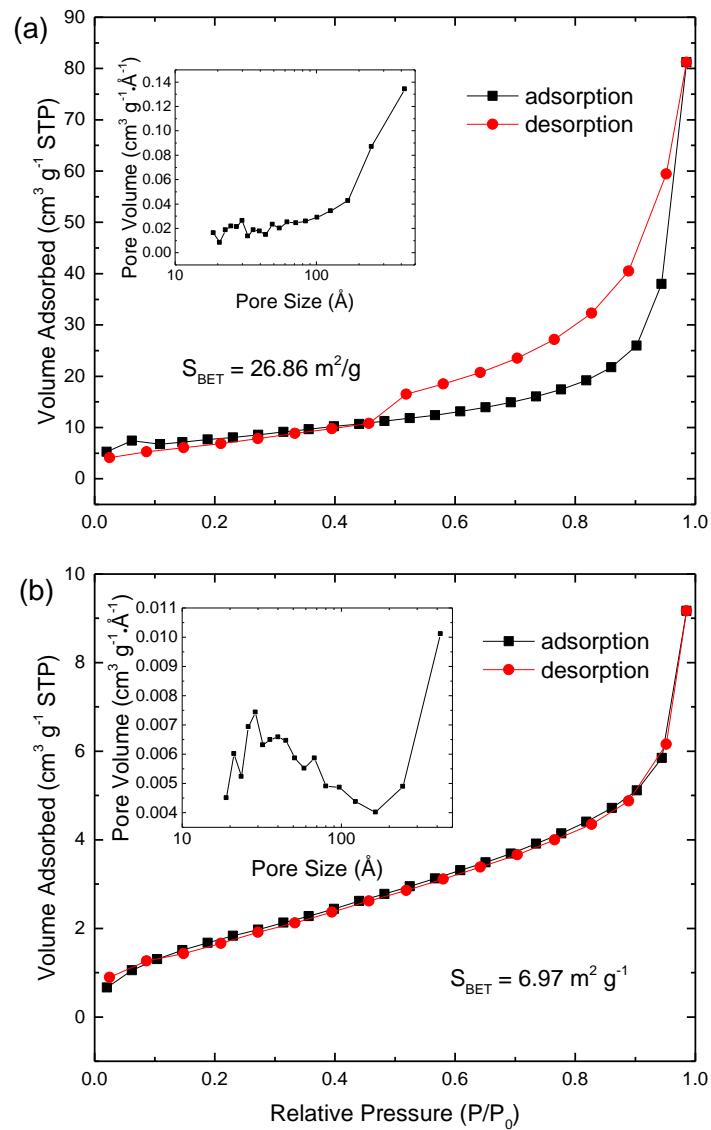
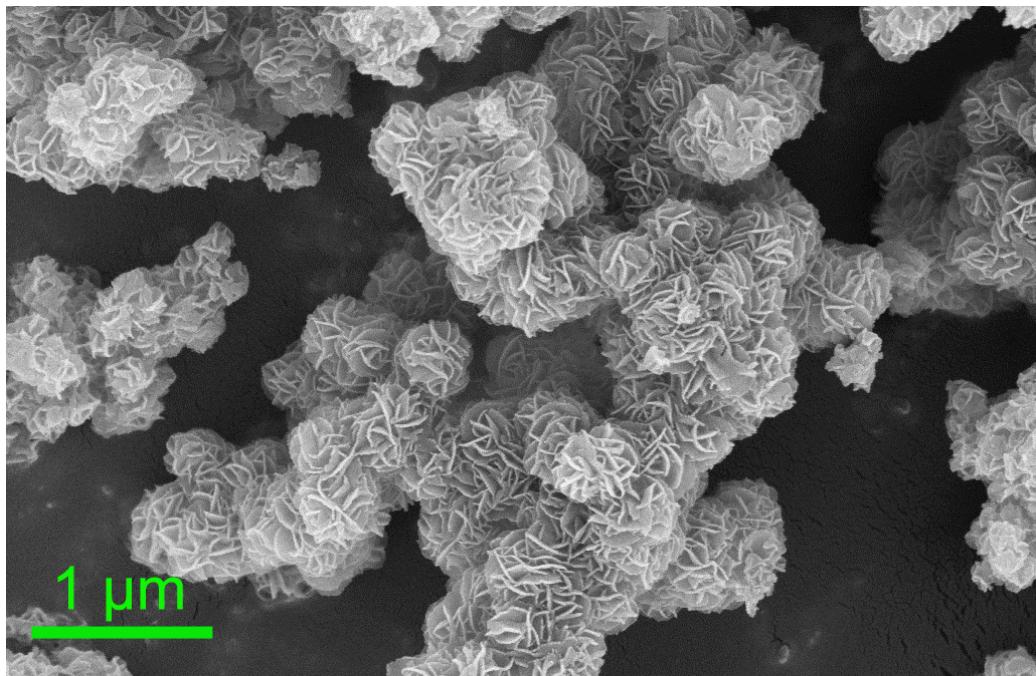


Fig. S3:  $N_2$  adsorption-desorption isotherms of (a) MoS<sub>2</sub>/NC-PNR and (b) S-MoS<sub>2</sub>. Insets are the pore distribution.



*Fig. S4: Morphology of S-MoS<sub>2</sub> synthesized by the same procedure but without adding DOPA.*

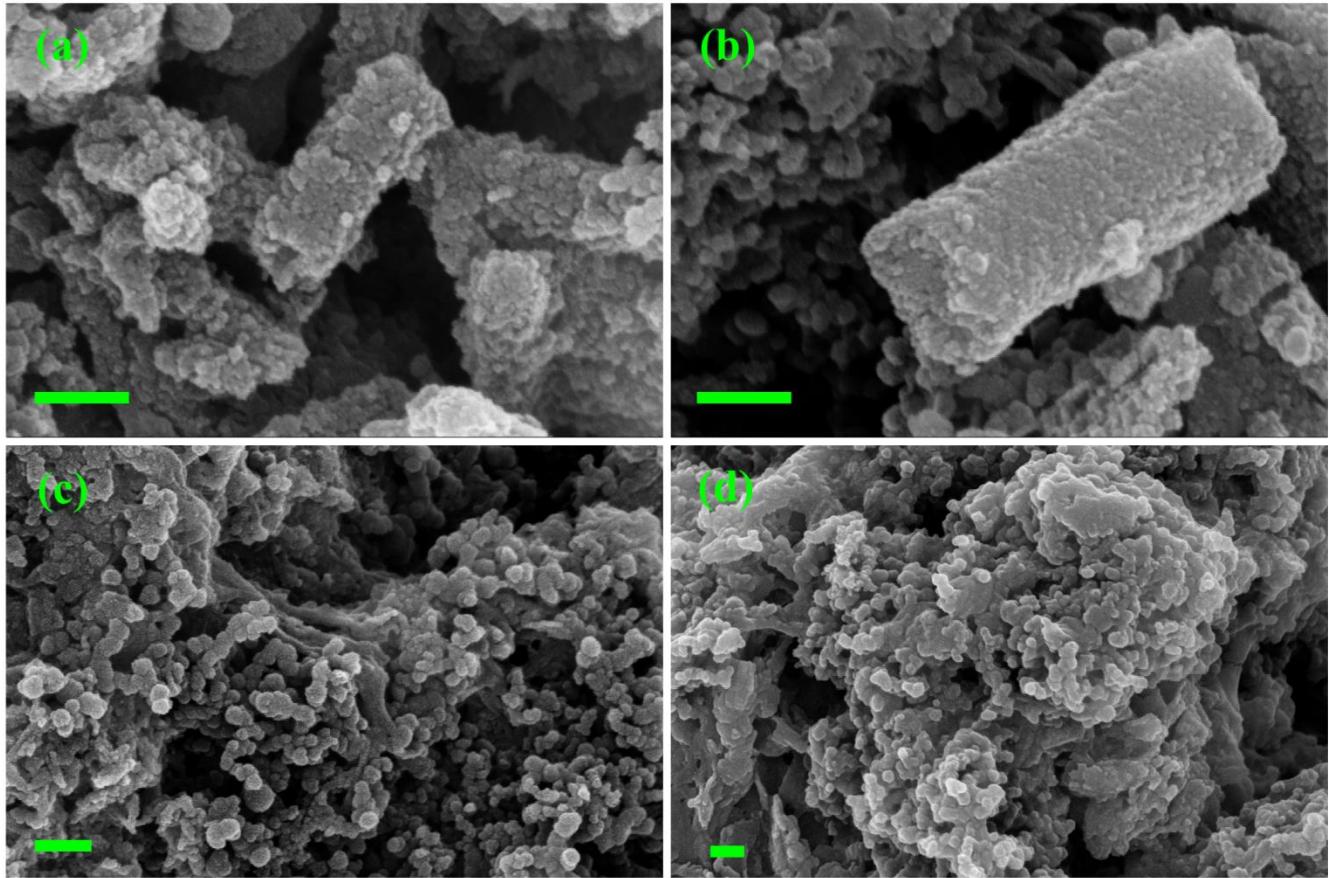


Fig. S5: SEM images of different samples after 150 cycles at 0.5 C: a~b for MoS<sub>2</sub>/NC-PNR superstructure; c~d for S-MoS<sub>2</sub>. The scale bar is 200 nm.

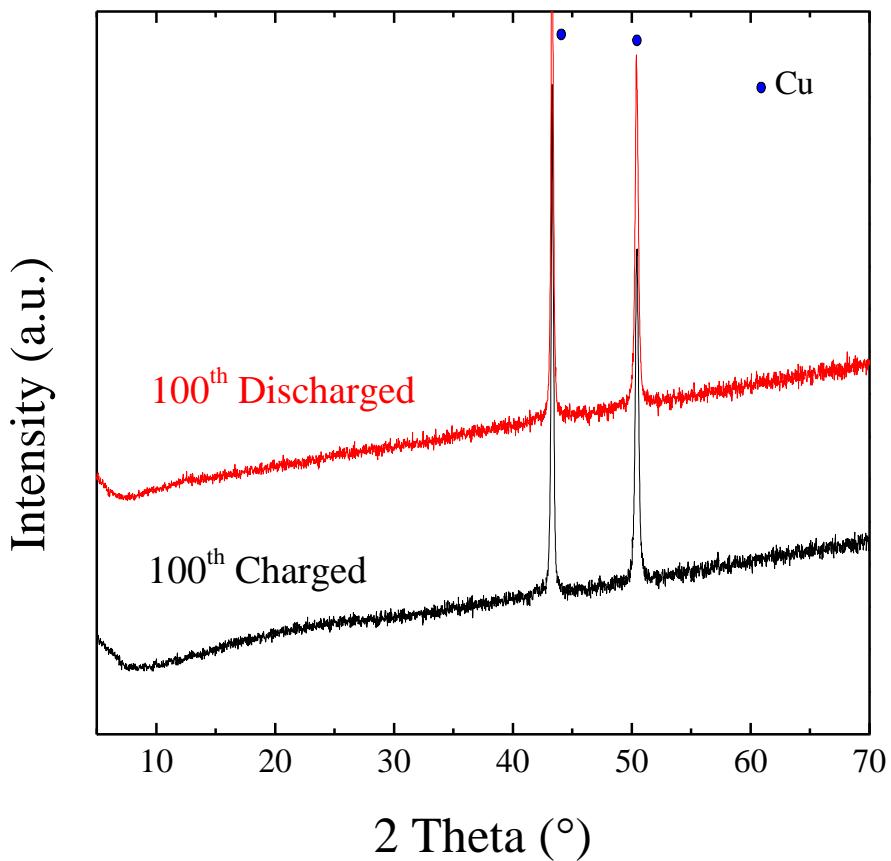
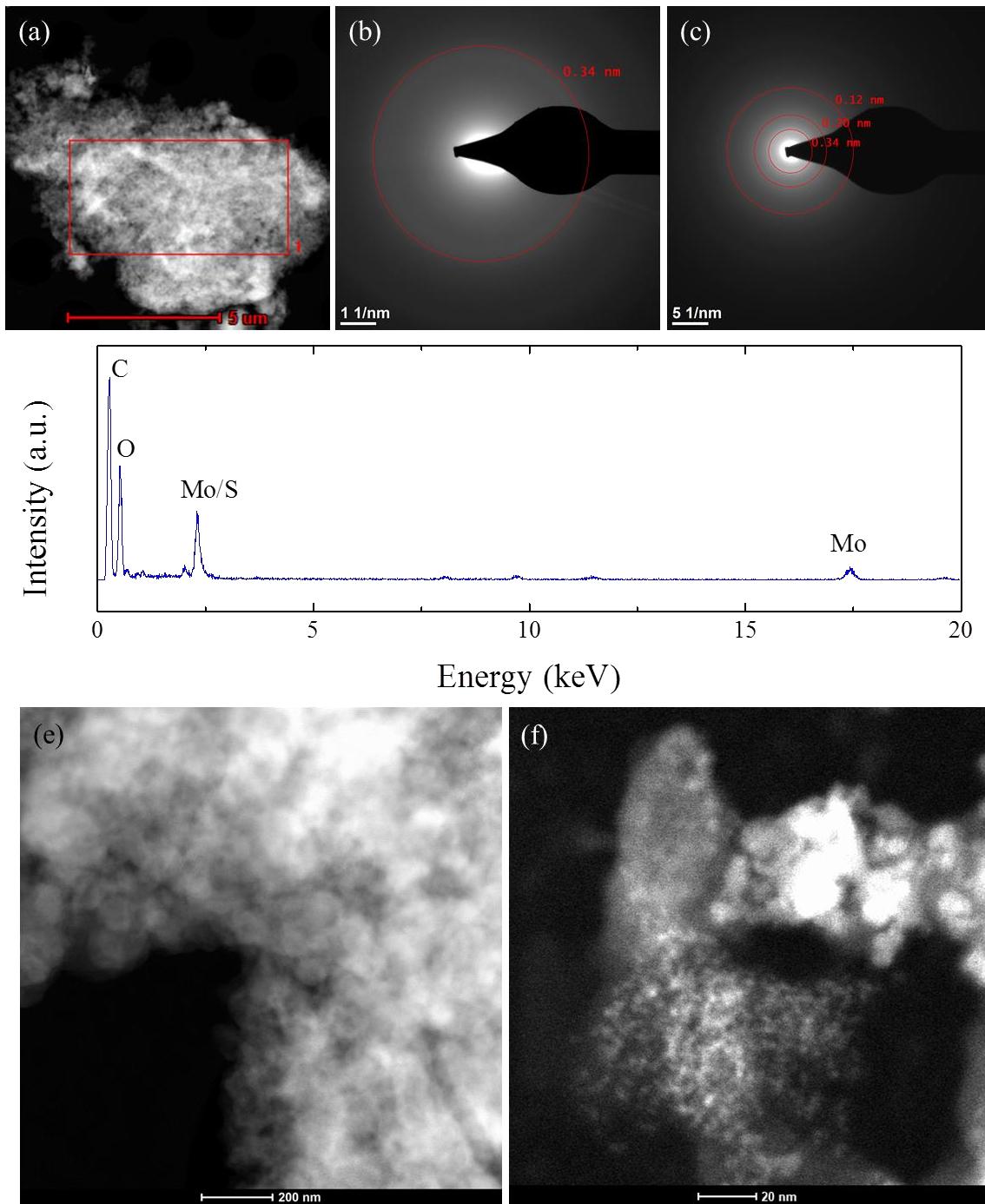


Fig. S6: XRD pattern of the MoS<sub>2</sub>/NC-PNR electrode at the 100<sup>th</sup> discharged and 100<sup>th</sup> charged states, respectively.



*Fig. S7 S/TEM study of the MoS<sub>2</sub>/NC-PNR electrode at the 100<sup>th</sup> charged state: (a) HAADF-STEM image; (b)~(c): SAED patterns of (a) with different camera length, the red rings label the reflections of carbon; (d) EDX spectrum of the red square area in (a); (e)~(f) HAADF-STEM images with higher magnification.*

TEM studies for the cycled electrode was performed using an aberration (image) corrected FEI Titan 80-300 microscope operated at 300 kV, equipped with a Gatan UltraScan CCD camera. The sample was prepared by dispersing the powder in dimethoxyethane, placing a drop on copper grids (Quantifoil Inc.) and taking of the residual suspension after natural drying in the glovebox.

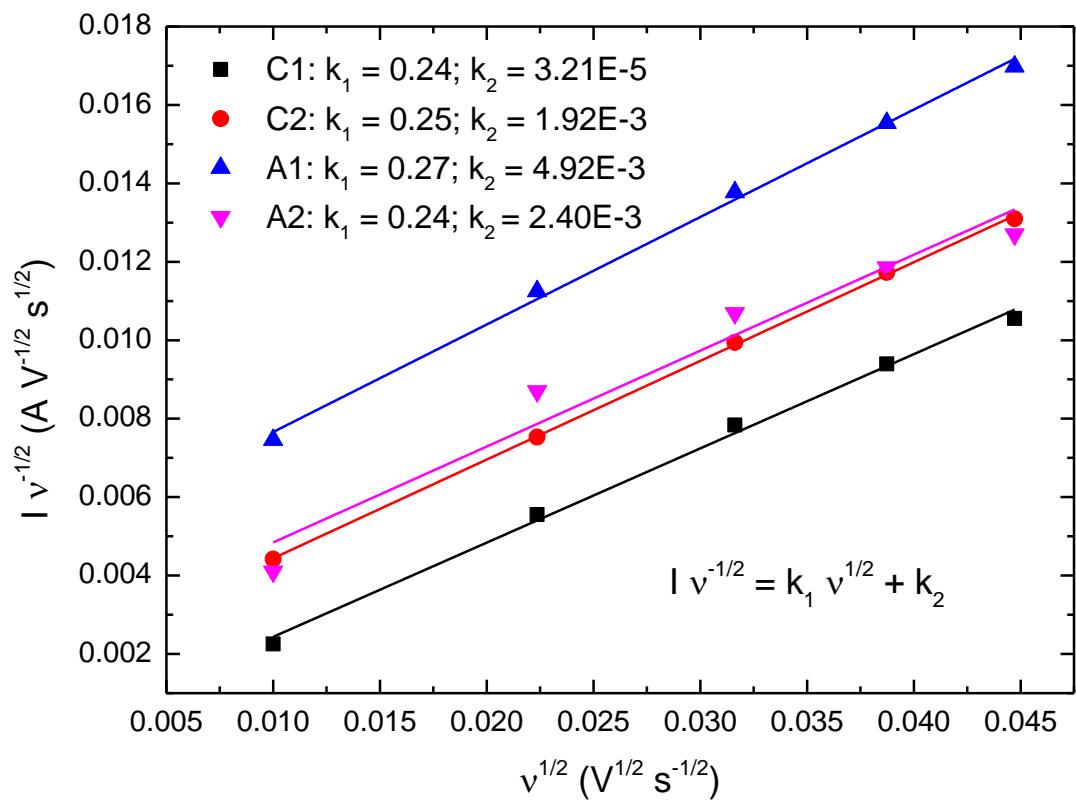


Fig. S8:  $I v^{-1/2}$  verses  $v^{1/2}$  plot of the MoS<sub>2</sub>/NC-PNR electrode.

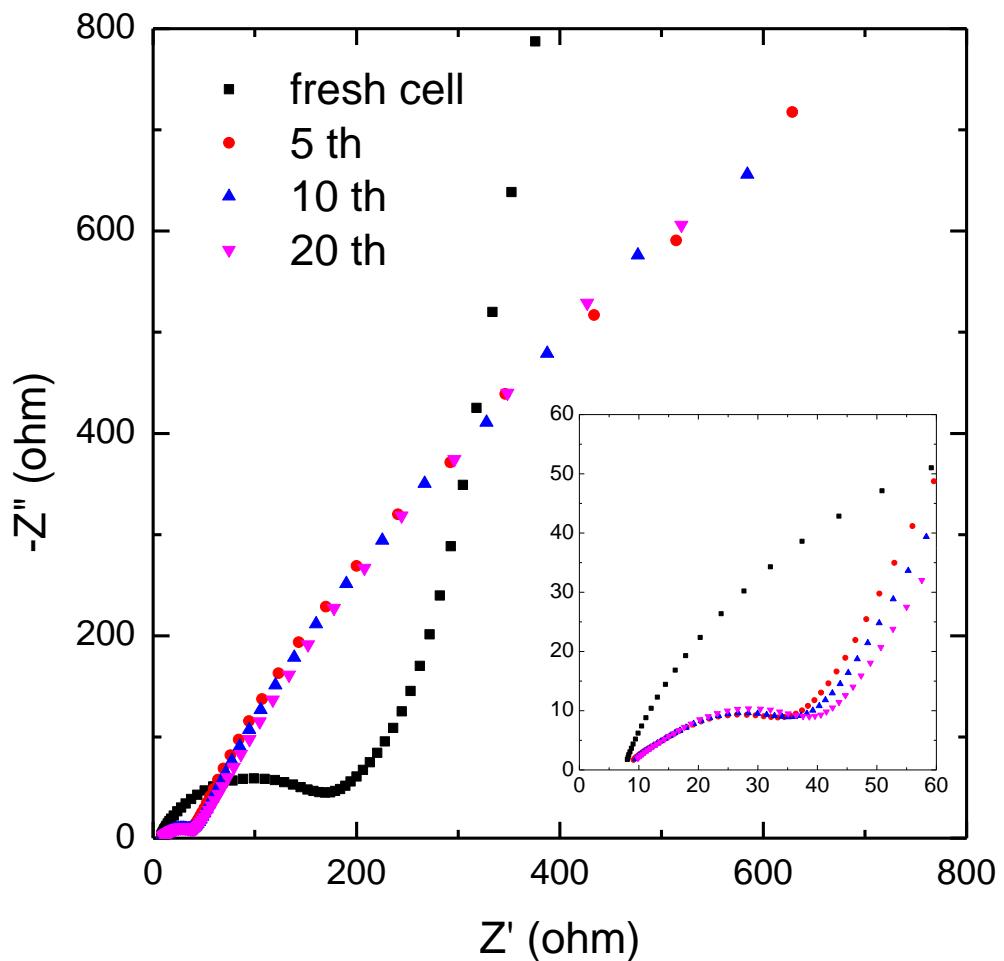
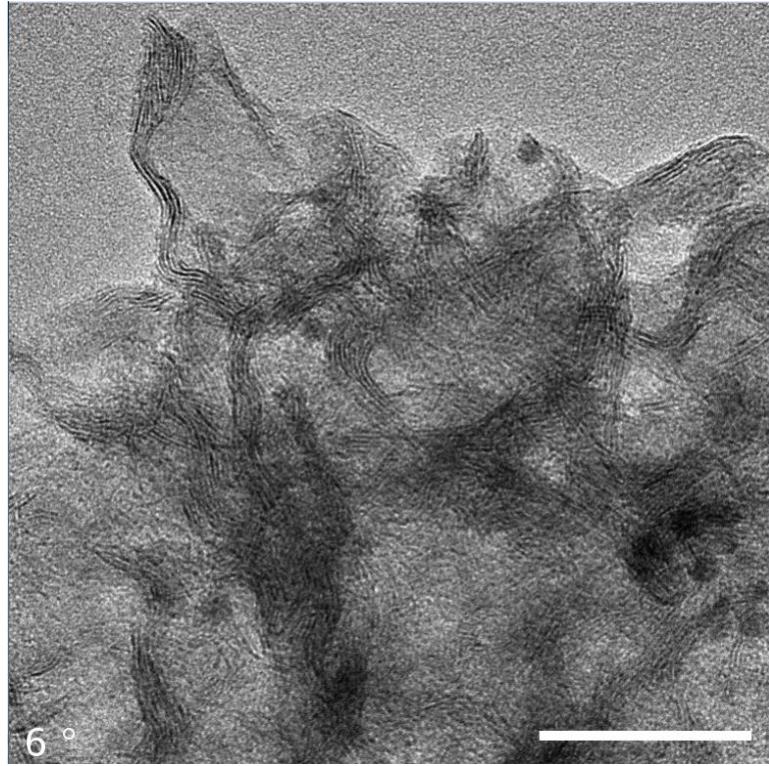


Fig. S9: Impedance measurements of the  $\text{MoS}_2/\text{NC}-\text{PNR}$  electrode before and after specific cycles at 0.5 C.



*Movie S1: HR-TEM tilt-series movie of the MoS<sub>2</sub>/NC-PNR superstructure in the range of -68° to + 64° with 1° steps. The scale bar is 50 nm.*

MoS <sub>2</sub> hierarchical structure	MoS <sub>2</sub> content (%)	Cycling stability (cycles)	Rate capability		Ref.
			Specific capacity (mA h g <sup>-1</sup> )	Current density (A g <sup>-1</sup> )	
MoS <sub>2</sub> /NC-PNR	74.2	700	925	0.067	Present work
			636	0.67	
			443	6.7	
MoS <sub>2</sub> HNS	-	100	944	0.1	1
			762	1	
			576	5	
CNTs@MoS <sub>2</sub> @C	79.8	500	960	0.1	2
			820	1	
			758	2	
NDG/MoS <sub>2</sub> /NDG	91.7	600	750	0.1	3
			589	1	
			416	4	
sS-MoS <sub>2</sub> @C	87.2	100	980	0.1	4
			~830	1	
			805	5	
MHPC	62.3	300	948	0.1	5
			725	1	
			496	10	
HMCM	71	300	915	0.1	6
			648	1	
			481	4	
mesoporous-carbon/MoS <sub>2</sub>	45	300	1400	0.1	7
			740	1	
			400	10	
MoS <sub>2</sub> @C nanotubes	82	300	1327	0.067	8
			993	0.67	

			850	3.35	
MoS <sub>2</sub> /CMK-3	70	150	893	0.1	9
			713	1	
			391	8	

Tab. S1: Battery performance comparison between this work and recently published MoS<sub>2</sub>-based hierarchical structures.

## Reference

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